Nanopatterning - Global Strategic Business Report

Description: This report analyzes the Global market for Nanopatterning in US$ Thousand by the following Technology Types - Nanoimprint Lithography (Hot Embossing Lithography, UV Nanoimprint Lithography, Soft Lithography, & Others), Scanning Probe Lithography, and Others. The Global market is further analyzed by the following End-Use Applications: Semiconductor & Other Microelectronics, and Others. Annual estimates and forecasts are provided for the period 2015 through 2022. Also, a six-year historic analysis is provided for this market. Market data and analytics are derived from primary and secondary research.

Company profiles are primarily based on public domain information including company URLs. The report profiles 35 companies including many key and niche players such as -

- AMO GmbH
- Canadian Photonics Fabrication Centre
- EV Group
- IMS Chips
- Micro Resist Technology GmbH

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8. FOCUS ON SELECT PLAYERS
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Canadian Photonics Fabrication Centre (Canada)
EV Group (Austria)
IMS Chips (Germany)
Micro Resist Technology GmbH (Germany)
Molecular Imprints, Inc. (US)
Nanonex Corp. (US)
NanoOpto Corp. (US)
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III. COMPETITIVE LANDSCAPE
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The United States (10)
Canada (1)
Japan (6)
Europe (17)
- France (2)
- Germany (7)
- Spain (1)
- Rest of Europe (7)
Asia-Pacific (Excluding Japan) (2)
Middle East (1)

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